

Introducing The Smallest Breakthrough in Ion Beam Processing...



V.A.L.L.

COMMONWEALTH SCIENTIFIC'S SMALL FOOTPRINT

**Variable Ange Load Lock
System**

Now you can have flexible, load locked ion beam processing in a system that doesn't take up your whole laboratory. But the best part is, it doesn't take up your entire budget either. Our new VALL™ system gives you the following features:

- o **Footprint of only 57" long by 53" deep**
- o **Substrate holder with variable incidence to any angle**
- o **Single or multiple wafer load lock**
- o **Reactive or inert ion beam etching**
- o **Ion beam sources from 3cm to 20cm**
- o **Microprocessor or computer controlled automation**



COMMONWEALTH SCIENTIFIC CORPORATION

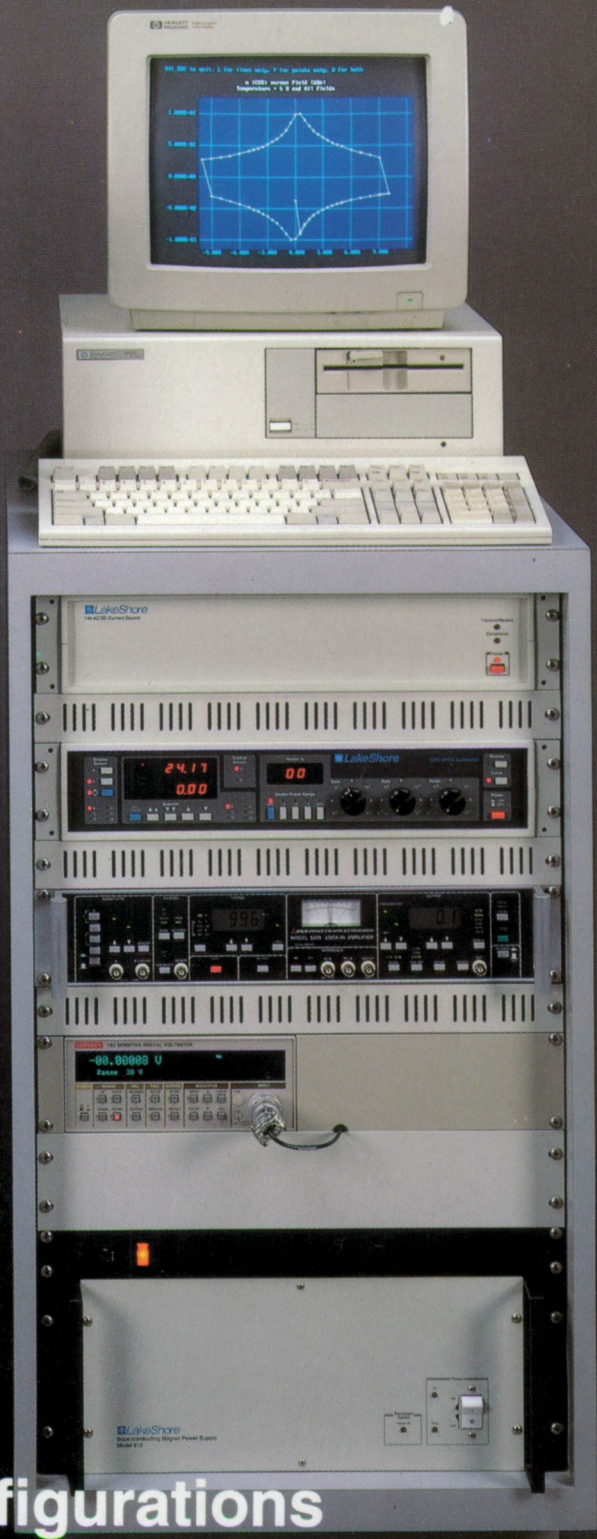
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Please visit Booth No. 703 at the MRS Equipment Exhibit in Boston, December 3-5, 1991.

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Your Source For Ion Beam Solutions

Systems
Starting
at \$39,600



- AC Susceptibility
- DC Moment
- Seven System Configurations

NEed We Say MORE? If so, call us at (614) 891-2243.



Please visit Booth No. 701-702 at the MRS Show in Boston, December 3-5, 1991.

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